9 . . *

Sheet 1 of 1

								eet 1 o	
J.S. Department of Commerce, Patent and Trademark Office					Atty. Docket 1	Serial No.			
					M-15212 US		Unassigned		
INFORMATION DISCLOSURE STATEMENT BY APPLICANT					Applicant(s)				
(Use several sheets if necessary)					Chia-Shun Hsiao et al.				
					Filing Date		Group		
					Herewith		Unassigned		
			U.S. I	Patent Documents					
Examiner nitial		Document Number	Dete	N	Class Subclass		Filing Date If Appropriate		
W	AA	2003/0067806	Date 10 Apr. 2003	Name Tuan	Class	Subclass	II Appro	ргіате	
M	AB	6,355,524	12 Mar. 2002	Tuan et al.					
pm)	AC	6,541,324	1 Apr. 2003	Wang					
	AD	-	1.1pi. 2003						
	AE			· · · · · · · · · · · · · · · · · · ·	 		· ·	 -	
	AF						 		
	AG					<u> </u>			
	AH	-	,				 	•	
	AI								
	AJ	 							
	 								
	AK	<u> </u>							
			Foreign	Patent Documents			Т. –		
•	T	Promote Prince Pr						Translation	
	1	Document	Date	Country	Class	Subclass	Yes	N	
	AL								
	AM					·			
	AN								
	AO					·			
	AP		·						
	•	OTHER A	ART (Including A	uthor, Title, Date, Pe	ertinent Pages, E	tc.)		_	
MD	AQ	K. Naruke et al., "A New Flash-Erase EEPROM Cell with a Sidewall Select-Gate on Its Source Side", IEDM Technical Digest 1989, pages 603-606.							
(>	AR	United States Application No.: 10/402,698 filed March 28, 2003 by Chung et al.							
M)		R. Mih et al., "0.18um Modular Triple Self-Aligned Embedded Split-Gate Flash Memory", 2000 Symposium on VLSI Technology, Digest of Technical Papers, pages 120-121.							
MB MD	AS	R. Mih et al., "0.1 Symposium on V	l 8um Modular Tr LSI Technology,	iple Self-Aligned Em Digest of Technical I	Papers, pages 12	te Flash Mem 0-121.	ory", 2000		
//	AS	Symposium on V	8um Modular Tr LSI Technology, Date Considere	Digest of Technical I	Papers, pages 12	te Flash Mem 0-121.			